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Sheet 1 of 1 NOV 2 7 2006

	FORM 1449* INFORMATION DISCLOSURE STATEMENT	Docket Number: 14434.103.USWO	Application Number: UNKNOWN		
	IN AN APPLICATION	Applicant: TAKEUCHI et al.			
(Use several sheets if necessary)		Filing Date: concurrent herewith	Group Art Unit: UNKNOWN		

		U.	S. PATENT DOCUMENTS			·	
EXAMINER INITIAL	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING D IF APPROP	
	2005/0079659	4.14.05	DUAN et al.				
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EXAMINER

DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form for next communication to the Applicant.

*Substitute Disclosure Statement Form (PTO-1449)

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